

Technical Specifications

multichannel 
systems

perforated MEA (Microelectrode Array) for MEA2100-32- and USB-MEA32-STIM4-System

**pMEA for use with
MEA2100-32- and
USB-MEA32-STIM4-
System**

Temperature compatibility

Dimension (W x D x H)

Base material

Perforation:

Total area of perforation

Diameter of the holes

Contact pad

Track material

Electrode diameter

Interelectrode distance

Electrode height

Electrode type

Isolation type

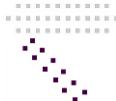
Electrode impedance

Electrode layout grid

Number of electrodes

Ring

pMEA-32S12 Layout 1



10 °C – 50 °C
49 x 25 mm x 180 µm
Polyimide foil on ceramic carrier with perforation

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

90 and 150 µm (record.electrode)
100 and 125 µm (stim. electrode)
Planar
Titanium nitride (TiN)

Polyimide foil
< 100 kΩ

1x10+1x12+1x10 (record. electr.)
2x6 (stimulation electrodes)
32 recording electrodes
12 stimulation electrodes
1 internal reference electrode
Without ring
Glass ring

pMEA-32S12 Layout 2



10 °C – 50 °C
49 x 25 mm x 180 µm
Polyimide foil on ceramic carrier with perforation

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

90 and 150 µm (record.electrode)
90 and 150 µm (stim. electrode)
Planar
Titanium nitride (TiN)

Polyimide foil
< 100 kΩ

1x10+1x12+1x10 (record. electr.)
2x6 (stimulation electrodes)
32 recording electrodes
12 stimulation electrodes
1 internal reference electrode
Without ring
Glass ring

pMEA-32S12 Layout 3



10 °C – 50 °C
49 x 25 mm x 180 µm
Polyimide foil on ceramic carrier with perforation

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

90 and 150 µm (record.electrode)
90 and 100 µm (stim. electrode)
Planar
Titanium nitride (TiN)

Polyimide foil
< 100 kΩ

1x10+1x12+1x10 (record. electr.)
3x4 (stimulation electrodes)
32 recording electrodes
12 stimulation electrodes
1 internal reference electrode
Without ring
Glass ring

pMEA-32S12 Layout 4



10 °C – 50 °C
49 x 25 mm x 180 µm
Polyimide foil on ceramic carrier with perforation

0.8 mm²
20, 30, 50, 75 and 90 µm

Titanium nitride (TiN)
Titanium (Ti)

30 µm (recording electrode)
50 µm (stimulation electrode)

100 and 100 µm (record.electr.)
100 and 100 µm (stim. electrode)
Planar
Titanium nitride (TiN)

Polyimide foil
< 100 kΩ

4x8 (recording electrode)
2x6 (stimulation electrodes)
32 recording electrodes
12 stimulation electrodes
1 internal reference electrode
Without ring
Glass ring